

Applications of High-Resolution MFM System with Low

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Abstract

Magnetic force microscopy (MFM) is very useful for observing magnetic domain structures. However, due to stray fields from a MFM probe, observations of small magnetic domain structures are limited. We have developed a high-resolution MFM system that utilizes a low moment probe and a Q-controlled probe-driver, which allows the sensitive measurement in a vacuum without disturbing domain structures. Using this system, resolution finer than 20nm was achieved. Here, advantages of this MFM are demonstrated using a honeycomb nano-network, a semicircular loop and a cross-shaped pattern.

1. What is MFM?

MFM image

Laser diode → Pre-Amp. → Phase detection → Cantilever (Output) → MFM image

Magnetic Probe → PZT (Input) → Stray field of sample → Test pattern of Hard disk (Horizontal recording media)

Attractive (Phase shift: Large)

Repulsive (Phase shift: Small)

Multi domain **Vortex** **Single domain**

Sample: Dr. Nakatani at NIMS

2. Unsolved Problems and Solution

Conventional Probe (High Moment Probe) → **Low Moment Probe**

Stray fields from conventional MFM probes often disturb domain structures of a sample.

Thickness of magnetic coat → Thinner

Advantages: Non-disturb, High-Resolution, Easy manufacturing

Closure domain of permalloy square film

Conventional MFM image

3. Low Moment Probe^[1]

CoPtCr sputtering

Tip (Si) diameter, thickness

SEM observation

M/Ms vs H (kOe) curves

M-H curve measurement: Ishio Lab., Akita University

[A] t = 72(nm) d = 70nm

[B] t = 48(nm) d = 50nm

[C] t = 24(nm) d = 30nm

[D] t = 12(nm) d = 20nm

[E] Non-coat d = 10nm

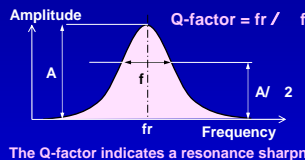
Conventional Probe → Low Moment Probe

Non-disturb

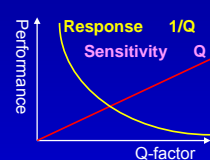
Small MFM sensitivity

4. MFM sensitivity

What is Q-factor ?



MFM sensitivity



Q-factor

$$\Delta\phi = \frac{Q}{K} \cdot \frac{\partial F}{\partial z}$$

: MFM signal (deg)

Q: Q-factor

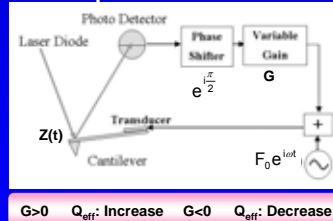
K: Spring constant of cantilever (N/m)

F/z: Force gradient (N/m)

There is a range of Q-factor with the stable and sensitive.

5. What is Q-control?

Principle of Q-control



Equation of motion

$$m\ddot{Z}(t) + \eta\dot{Z}(t) + kZ(t) = F_0 e^{i\omega t} + Ge^{\frac{i\omega}{2}} Z(t)$$

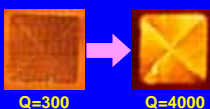
$$m\ddot{Z}(t) + \eta_{\text{eff}}\dot{Z}(t) + kZ(t) = F_0 e^{i\omega t}$$

Effective viscous coefficient

$$\eta_{\text{eff}} = \eta - \frac{G}{\omega}$$

Effective Q-factor

$$Q_{\text{eff}} = \frac{m\omega}{\eta_{\text{eff}}} = \frac{m\omega}{\eta - \frac{G}{\omega}}$$

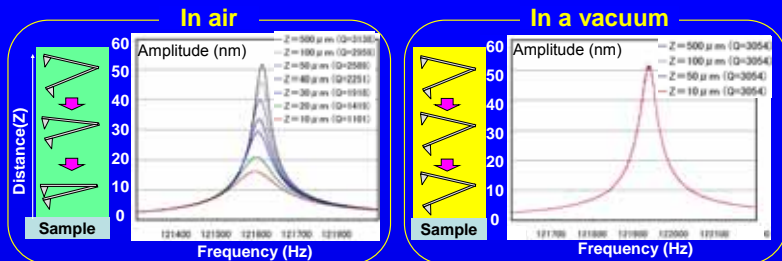


B. Anczykowski et al, Appl. Phys. A66, pp.885-889, 1998.

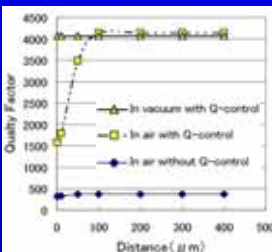
A.D.L. Humphris et al, Surface Science, Vol.491, No.3, pp.468-472, 2001.

6. Comparison of Q-control in Air / in a Vacuum

Changes of Q-curve when approaching the probe close to the sample



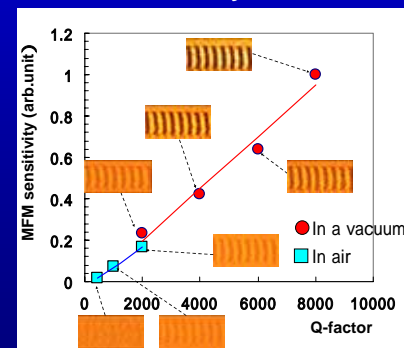
Distance dependence with Q-factor



Q-curve and Q-factor in air is influenced by the change of the viscous drag.

This phenomenon isn't desirable in MFM measurement.

Relation between Q-factor and MFM sensitivity



Cantilever
Resonance frequency 250 ~ 300kHz
Spring constant 40N/m
Low moment probe (t=24nm)

Sample
Perpendicular recording medium
200kFCI (Bit length: 127nm)

Range of stable Q
in air: 200 Q 2000
in a vacuum: 2000 Q 8000

Q-control in a vacuum is higher sensitivity and wider range of stable Q-factor[1].

Moment Probe and Q-control in a Vacuum

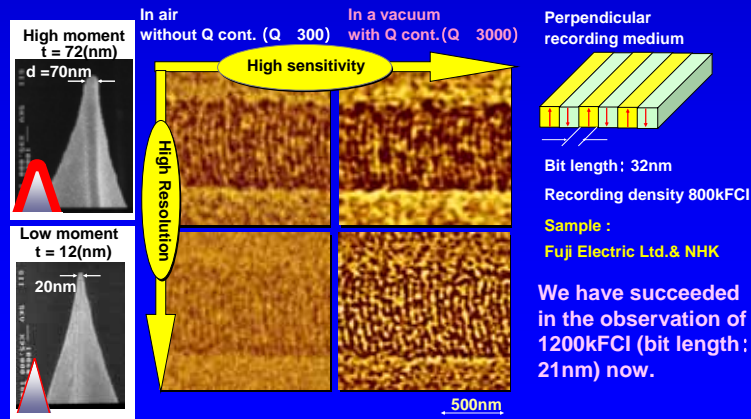
(1) SII NanoTechnology Inc. 261-8507 Chiba, Japan (2) Dept. of Phys., Keio Univ. 270-2222 Yokohama, Japan

7. High-Resolution MFM System

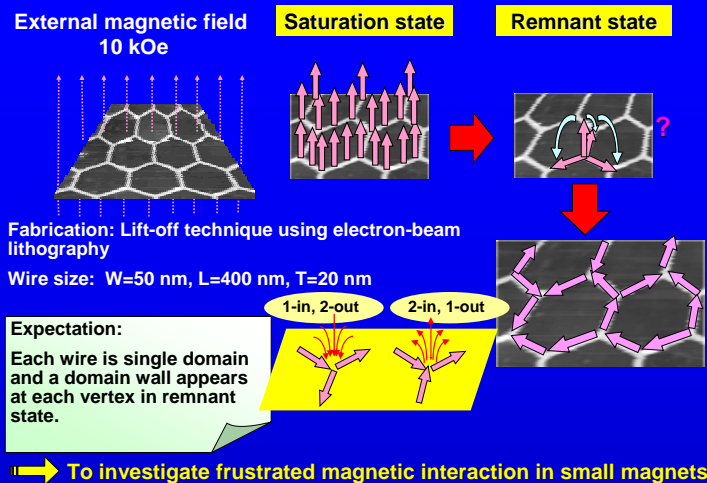


Environment Controllable SPM
 (In air, in a vacuum and in liquid)
 P : 10^{-5} (Pa) by a turbo molecule pump
 T : - 140 ~ + 800 () by LN₂ and a heater
 SPI4000/ E-sweep and SPA300HV,
 SII NanoTechnology Inc.

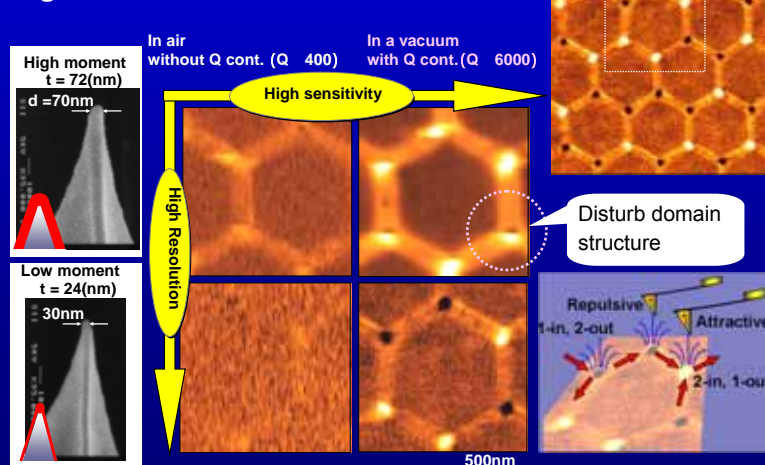
8. Perpendicular Recording Media^[1]



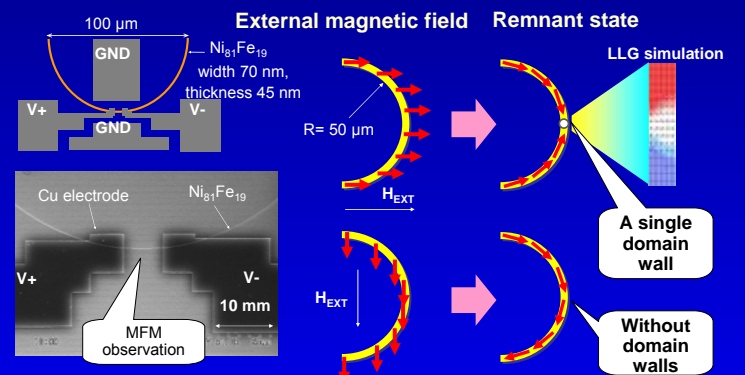
9. NiFe Honeycomb Nano-Network^[2]



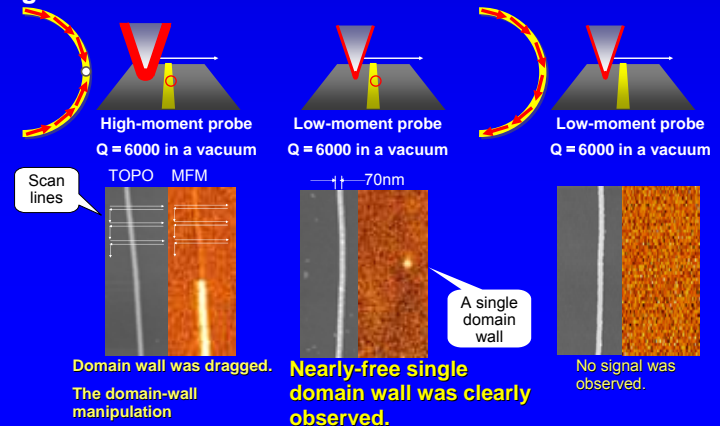
High-Resolution MFM observations



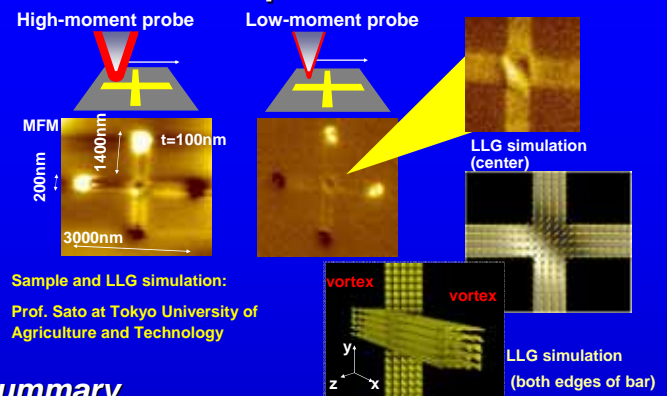
10. NiFe Semicircular Wire Loop^[3]



High-Resolution MFM observations



11. NiFe Cross-Shaped Pattern



Summary

We have demonstrated the effectiveness of the high-resolution MFM that involves the use of a low moment probe and Q-control system in a vacuum. Standard high moment probe disturbs the domain structure of the sample. In contrast, the low moment probe allows the stable and clear observation of magnetic domain. The high-resolution MFM with low-moment probe and Q-control in a vacuum should be powerful for exploring nano-scale magnetism.

Acknowledgment

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Reference

- [1] T. Yamaoka, K. Watanabe, Y. Shirakawabe, and K. Chinone, "High-Sensitivity, High-Resolution Magnetic Force Microscopy System," J. Magn. Soc. Jpn., vol.27, pp.429-433, 2003.
- [2] E. Saitoh, M. Tanaka, H. Miyajima, and T. Yamaoka, "Domain-wall trapping in a ferromagnetic nano-wire network," J. Appl. Phys., vol.93, no.10, pp.7444-7446, 2003.
- [3] E. Saitoh, H. Miyajima, T. Yamaoka, and G. Tatara, "Current-induced resonance and mass determination of a single magnetic domain wall," Nature, vol.432, pp.203-206, 2004.